

ELECTION

On Page 2 of the first Office action, Applicant's pending claims were determined to be directed to the following plurality of patentably distinct inventions:

Group I: Claims 1-46 and 50-54, drawn to a method for plasma etching a semiconductor substrate, classified in class 438, subclass 585(+);

Group II: Claims 47-49, drawn to semiconductor device, classified in class 257, subclass 1(+).

In response to the restriction requirement contained in the Office Action, Applicants hereby elect without traverse for prosecution purposes the Claims of Group I, namely Claims 1-46 and 50-54.